

STN 4 Caplus

(FILE 'HOME' ENTERED AT 20:44:36 ON 20 MAY 2005)

FILE 'REGISTRY' ENTERED AT 20:44:41 ON 20 MAY 2005

L1 0 S ALICYCLIC/CNS AND ACYLATE/CNS  
L2 0 S ?ALICYCLIC?/CNS AND ?ACRYLATE?/CNS  
L3 9 S ?ALICYCLIC?/CNS

FILE 'CAPLUS' ENTERED AT 20:46:12 ON 20 MAY 2005

L4 130789 S RESIST OR PHOTORESIST OR MASK OR PHOTOMASK  
L5 1329242 S ETCH? OR PATTERN? OR REMOV?  
L6 1329242 S ETCH? OR PATTERN? OR REMOV?  
L7 19060 S ?ALICYCLIC?  
L8 347379 S ?ACRYLAT?  
L9 717684 S RESIN?  
L10 132 S L7(10A)L8(10A)L9  
L11 6 S L4 AND L10 AND L6  
L12 0 S L3 AND L4 AND L6  
L13 569 S L7(10A)L8  
L14 59 S L13 AND L4 AND L6

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L15 53 S L14 NOT L11  
L16 62 S L13(10A)L4  
L17 35 S L15 AND L16  
L18 27 S L16 NOT L17

East 8 USPB, USPT, WPI, JPO

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	788	alicylic or "alicylic"	US-PGPUB; USPAT	OR	OFF	2005/05/20 16:07
L2	2426425	etch\$ or patern\$ or remov\$	US-PGPUB; USPAT	OR	OFF	2005/05/20 16:07
L3	32	1 same 2	US-PGPUB; USPAT	OR	OFF	2005/05/20 15:56
L4	3034217	temp or temperature or c or celcius or centrigrade or "liq\$ n2" or "liq\$ nitrogen"	US-PGPUB; USPAT	OR	OFF	2005/05/20 16:07
L5	915968	cool\$	US-PGPUB; USPAT	OR	OFF	2005/05/20 16:07
L6	5	3 same (4 or 5)	US-PGPUB; USPAT	OR	OFF	2005/05/20 15:58
L7	5	3 same (4 or 5)	US-PGPUB; USPAT	OR	OFF	2005/05/20 15:59
L8	473333	resist or photoresist or mask or photomask	US-PGPUB; USPAT	OR	ON	2005/05/20 16:08
L9	0	7 same 8	US-PGPUB; USPAT	OR	ON	2005/05/20 15:59
L10	46679	2 same (4 or 5) same 8	US-PGPUB; USPAT	OR	ON	2005/05/20 16:00
L11	45	1 same 8	US-PGPUB; USPAT	OR	ON	2005/05/20 16:00
L12	22	10 and 11	US-PGPUB; USPAT	OR	ON	2005/05/20 16:00
L13	27	7 or 12	US-PGPUB; USPAT	OR	ON	2005/05/20 16:01
L14	344	alicylic or "alicylic"	JPO; DERWENT	OR	OFF	2005/05/20 16:07
L15	1670960	etch\$ or patern\$ or remov\$	JPO; DERWENT	OR	OFF	2005/05/20 16:07
L16	10082287	temp or temperature or c or celcius or centrigrade or "liq\$ n2" or "liq\$ nitrogen"	JPO; DERWENT	OR	OFF	2005/05/20 16:07
L17	761398	cool\$	JPO; DERWENT	OR	OFF	2005/05/20 16:08
L18	340668	resist or photoresist or mask or photomask	JPO; DERWENT	OR	ON	2005/05/20 16:08
L19	1	14 and 15 and (16 or 17) and 18	JPO; DERWENT	OR	ON	2005/05/20 16:09
L20	6	14 and 15 and 18	JPO; DERWENT	OR	ON	2005/05/20 16:09
L21	5	20 not 19	JPO; DERWENT	OR	ON	2005/05/20 16:10

L22	0	1 with 8	JPO; DERWENT	OR	ON	2005/05/20 16:10
L23	17	1 with 8	US-PGPUB; USPAT	OR	ON	2005/05/20 16:10
L24	9	2 same 23	US-PGPUB; USPAT	OR	ON	2005/05/20 16:10
L25	5	24 not 13	US-PGPUB; USPAT	OR	ON	2005/05/20 16:11
L26	4	24 not 25	US-PGPUB; USPAT	OR	ON	2005/05/20 16:11